

14th International Conference on Nuclear Microprobe Technology and Applications

Thursday, 10 July 2014

Session 6 - Nuclear Microprobe Applications: Ion Beam Material Micro-Modification - Auditorium (08:30 - 10:10)

-Conveners: Paolo Olivero

time	[id] title	presenter
08:30	[100] MeV ion beam mask lithography of parylene-C and parylene-F	Prof. WHITLOW, Harry J.
09:00	[97] Ion beam writing on diamond in micrometer scale at the LIPSION nanoprobe	Mr LUHMANN, Tobias
09:30	[141] Deep Ion Beam Lithography in diamond: towards the nanoscale	Dr PICOLLO, Federico
09:50	[4] The use of focused ion beams for the realization of nano-structures in diamond	Prof. KALISH, Rafi